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# Machine Learning-Based Intelligent Industry 4.0 Control Systems for Manufacturing

Guest Editors:

#### Dr. Alex Shenfield

Department of Engineering and Mathematics, Sheffield Hallam University, Sheffield, UK

### Dr. Hongwei Zhang

National Centre of Excellence for Food Engineering, Sheffield Hallam University, Howard Street, Sheffield S1 1WB, UK

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# **Message from the Guest Editors**

This Special Issue on "Machine Learning-Based Intelligent Industry 4.0 Control Systems for Manufacturing" aims to cover recent advances in the development of intelligent AI/ML-based control systems for manufacturing processes. Topics of interest include, but are not limited to:

- Al-based computer vision applications for quality control in manufacturing processes;
- Intelligent machine monitoring systems;
- Edge applications of AI/ML for manufacturing processes;
- Data issues (such as federated data sharing, deduplication, data privacy and ethical concerns);
- Intelligent systems for enabling low-carbon (and net-zero) manufacturing processes.











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## **Editor-in-Chief**

# Prof. Dr. Giancarlo Cravotto

Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

# Message from the Editor-in-Chief

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